

# CMOS Low Voltage LNA with Improved Noise Figure

Najeemulla Baig, Fazal Noorbasha

**Abstract :** In this research paper the designing of 1.5754GHz low Noise Amplifier integrated with a 90nm CMOS process using RF-spectre is presented. The intended circuit exhibits power gain of 19.82dB;  $S_{12}$  of -31.10dB, noise figure of 0.462m dB, 1-dB compression point of -14.57m dB and IIP3 equal to -12.557m dB at low power supply of 0.7 V.

**Keywords-** Low Noise Amplifier (LNA), Global positioning system (GPS), Impedance matching, Noise figure (NF), 3<sup>rd</sup> order input intercept point (IIP<sub>3</sub>) Gain.

## I. INTRODUCTION

The available GPS receivers compel to design better performing, lesser cost receivers. The  $L_1$  frequency of GPS signal is 1575.42 MHz. LNA is the key part of the GPS receiver. The important role of LNA is to give adequate power gain to trounce the noise of successive stages [1].

An LNA circuit using resistive feedback and gain peaking technique is used in [11] but results in high NF. In this research work, a low voltage CMOS RLC tuned LNA is planned.

This paper is prepared as follows: In Section2, a tuned RLC CMOS LNA circuit design is planned. Section3 shows the simulation results. Section4 describes the s-parameter study of the LNA design .lastly; some conclusions are given in Section5.

## 2. Design of the planned LNA circuit

The designed circuit is shown in Figure1. The inductors  $L_1$  and  $L_2$  are selected to give the chosen input resistance ( $R_s$ ).  $L_3$ ,  $R_1$ , and  $C_1$  form a resonant circuit to refrain the LNA to 1575.4MHz.

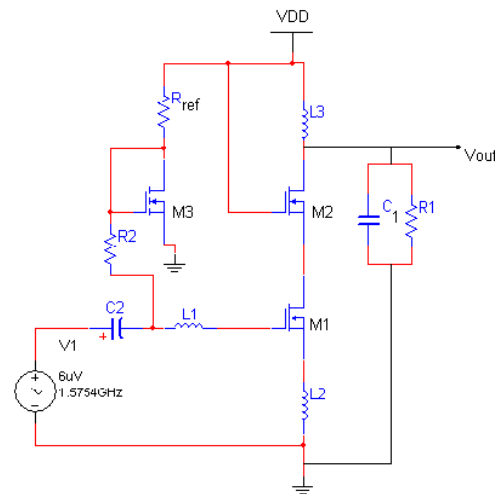


Fig.1.The circuit of CS LNA [12]

A current mirror is formed with  $M_1$  using transistor  $M_3$ . The width of  $M_3$  is little part of the width of  $M_1$ . This will decrease the extra power consumption by the bias circuit.

Resistor  $R_{ref}$ , selected to provide low NF and small power dissipation in combination with the  $V_{gs}$  of  $M_3$ . Equivalent noise current of  $R_2$  is negligible if larger value is selected for  $R_2$ .

### 2.1. Calculating circuit components values

**Step 1:** Designing  $L_2(L_s)$  by real part toning condition, presume that  $R_s = 50 \Omega$   
Input matching state gives

$$R_s = \frac{g_m}{C} L_2 = \omega_T L_2 = 2\pi f_T L_2 \quad (1)$$

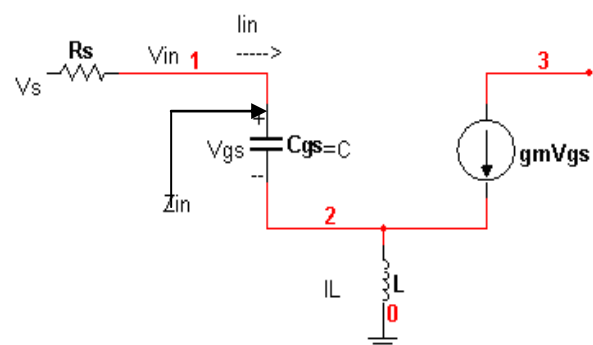


Fig.2. Small signal equivalent circuit of LNA [1]

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For a MOS transistor  $f_T$  is called as unity gain frequency there fore

$$2\pi f_T = \frac{g_m}{C}$$

Therefore, 
$$L_2 = \frac{50\Omega}{2\pi f_T} \quad (2)$$

For 90nm technology,  $f_T = 25\text{GHz}$  then inductor  $L_2$  is  $0.159\text{ nH}$ , taking into consideration a little higher value for  $L_2$  than deliberate value in simulation, as the noise penalty of undue  $L_2$  is a lot less severe than for deficient  $L_2$  [5].

**Step2:** design  $L_1(L_g)$  using NF condition

According to specification  $\text{NF} < 2\text{dB}$ , from the NF equation [4]

$$\text{NF} = 1 + \frac{2}{3} \frac{1}{1 + \frac{L_1}{L_2}} < 2 \quad \text{Solving yields}$$

$$\frac{L_1}{L_2} > \frac{1}{3} \Rightarrow L_1 > \frac{L_2}{3}$$

Let  $L_1 = 1\text{ nH}$ .

**Step3:** Designing  $C = C_{gs}$  using imaginary part toning

condition 
$$\omega_c (L_1 + L_2) = \frac{1}{\omega_c C}$$

$$C = \frac{1}{\omega_c^2 (L_1 + L_2)} \quad (4)$$

With  $\omega_c = 2\pi(1.5754)10^9 \text{ rad/s}$  and using  $L_1$  and  $L_2$  values the value of  $C$  is  $7456.68\text{ fF}$  we have that [4]

$$C = C_{gs} = \frac{2}{3} W L C_{ox} \quad (5)$$

$$C_{ox} = (\epsilon_{ox} / t_{ox}) = 13.466 \times 10^{-3}$$

From equation (5)

$$W_1 = \frac{C}{\frac{2}{3} C_{ox} L_1}$$

For ease consider  $(W/L_1) = (W/L_2)$

Here we got the M1 transistor width; for selecting M2 width following cases we can observe. When  $W_1 = W_2$  LNA gives superior NF when compared to the NF resulting by taking  $(W/L_1) = 2(W/L_2)$ , but this gives better gain. If we take  $(W/L_1) = \frac{1}{2}(W/L_2)$  noise figure and gain both degrades.

**Step 4:** Finding  $L_3, C_1, R_1$  by using parallel toned circuit equations

$$\text{This is given by: } \omega_0 = \frac{1}{\sqrt{LC}}$$

$$\text{where } \omega_0 = 2\pi f_0$$

Assuming  $L_3$  and finding  $C_1$  for optimum results.

$L_3 = 10.2\text{ nH}$ ,  $C_1 = 46.2\text{ fF}$  and using  $R = 2\pi \sqrt{\frac{L}{C}}$  to get  $R_1 = 4.6\text{ Kohms}$  (after optimizing for gain).

### 3. Results and discussions

The planned LNA is simulated using the RF-spectre simulator. For a range of  $L_g$  and  $L_s$  values S-parameters and NF analysis is performed, at the designed frequency.

To bias transistor M1 current mirror circuit is used, with different widths ( $W_3$ ) for current mirror transistor M3. S-parameters, NF, VG and power dissipation (PD) variations with different widths for transistor M3 are shown in the table no.2. A better NF results without current mirror circuit but the additional supply is essential for biasing M1.

#### 3.1. Noise Figure (NF)

In figure 3 NF variations with respect to frequency are shown. Initial simulating noise figure (NF) Vs frequency gives a NF of  $633.8\text{ mdB}$  at  $1.5754\text{ GHz}$  shown in Figure.3.

$L_g$  Vs NF gives the subsequent results, at  $L_g = 10.3\text{ nH}$  which is higher than the planned value ( $L_g = 7\text{ nH}$ )  $\text{NF} = 461.85\text{ mdB}$ , an additional increase in  $L_g$  results in improved NF but the setback is the area in use by the inductor is very large this is shown in figure 4.

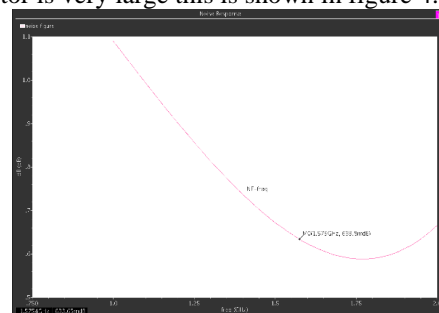


Fig.3. NF Vs frequency

Also,  $L_s$  Vs NF analysis results that  $L_s$  decreased NF better,  $L_s$  less than 160pH; NF is almost constant at 628mdB.

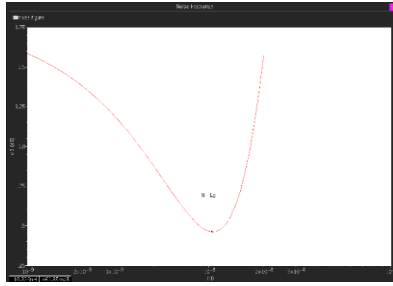


Fig.4. NF Vs  $L_g$

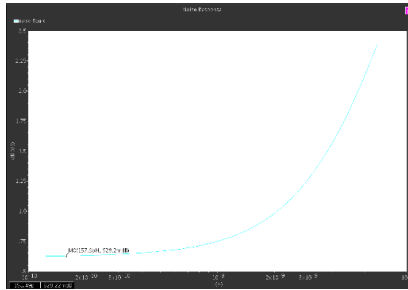


Fig.5. NF Vs  $L_s$

### 3.2. S-parameters

Simulating S-parameters Vs frequency the results are shown in figure.6 and specified in Table .1.

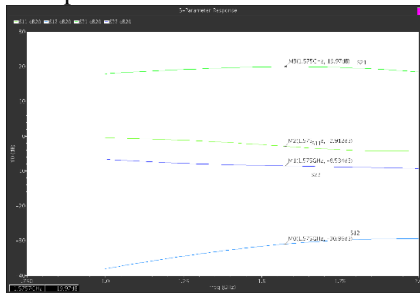


Fig.6. S-parameters Vs Frequency

When  $L_s$  Vs S-parameter analysis is performed, for  $L_s = 623.38pH$   $S_{11}$  value is best and above or below this value  $S_{11}$  is corrupting, similarly  $S_{12}$  is degrading above 227pH and as  $L_s$  is decreased  $S_{21}$  and  $S_{22}$  are improving. This two component analysis is shown in figure.7 and figure.8.

Similarly  $L_g$  Vs S-parameters analysis gives that  $S_{11}$  is -3.88dB at  $L_g=9.5nH$  and corrupting for above or below this value.

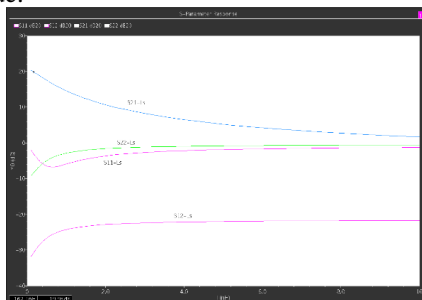


Fig.7. S-parameters Vs  $L_s$

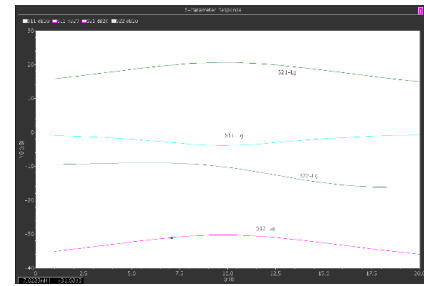


Fig.8. S-parameters Vs  $L_g$

Table.1. Simulating S-parameters Vs frequency

	$S_{11}$ (dB)	$S_{12}$ (dB)	$S_{21}$ (dB)	$S_{22}$ (dB)
$f=1.5754G$ Hz	-2.912	-30.96	19.97	-8.534

### 3.3. Linearity

Non-linear behavior of the active devices operating at RF frequency should be considered. For large RF signals used as input these devices produce spurious signals. 1-dB compression point and  $IIP_3$  are used to verify the linearity of LNA [1].

#### 3.3.1-dB Compression Point:

For the LNA designed 1-dB compression point is equal to -14.57mdB, and meets to the specification. We can observe that in figure 9.

3.3.2  $IIP_3$ : Better the  $IIP_3$  of LNA, the healthier its linearity.  $IIP_3$  obtained was-12.5477mdB we can observe it in figure10.

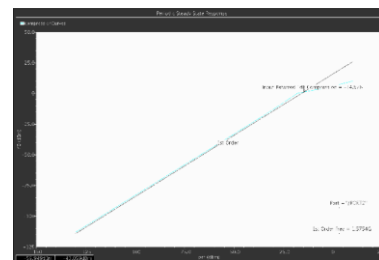


Fig.9. 1-dB Compression point

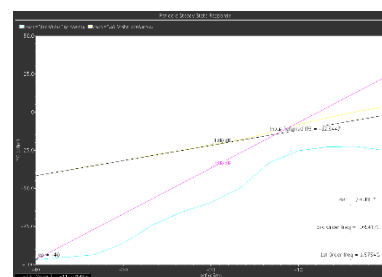
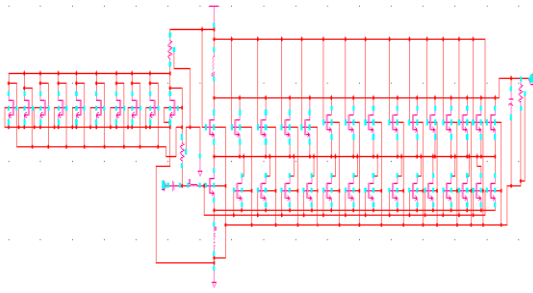
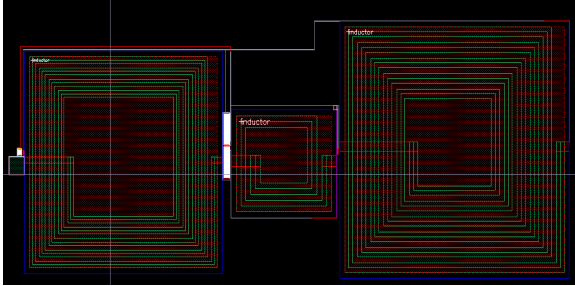


Fig.10.  $IIP_3$  measurement

Simulated schematic of cascode LNA using a current mirror is shown in figure 11 and the Layout of LNA with a current mirror is shown in figure 12.



**Fig.11. simulated schematic of LNA with current mirror.**



**Fig.12. Layout of LNA with current mirror**

**Table 2. Performance of the proposed LNA**

with different widths of biasing transistor  $M_3$

$W_3$	$W_1/5$	$W_1/10$	$W_1/20$
NF(dB)	1.3	0.88	0.63
S11(dB)	-1.91	-2.37	-2.92
S12(dB)	-30.32	-30.84	-31.1
S21(dB)	15.52	17.96	19.82
S22(dB)	-4.84	-6.66	-9
VG(dB)	16.37	17.82	19.73
I (mA)	21.79	26.46	33.89
PD(mW)	15.25	18.5	23.72

PD: POWER DISSIPATION VG: VOLTAGE GAIN

## II. CONCLUSION

A low voltage CMOS LNA with operating frequency of 1575.4MHz was designed using the CMOS 90nm process with an RF-spectre circuit simulator. The intended LNA exhibits power gain of 19.82db,  $S_{12}$  of -31.10dB, 1-dB compression point of -14.57mdB and IIP3 equal to -12.557mdB. The computer-generated results for the LNA show high VG, low NF, and low power dissipation at a low power supply voltage of 0.7v.

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